Characterization of Second Harmonic Afterburner Radiation at the

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Utilizing the Micro-Bunched Electron Beam

- At FEL saturation, the electron beam is highly micro-bunched at odd and even harmonics.
- Adding extra undulators (resonant at any of these harmonics but with different parameters) can be used to produce an additional <u>FEL quality</u> photon beam with properties such as
 - Enhanced harmonics content
 - Various types of planar and circular polarization (fundamental or 2nd harmonic)

R. *Bonifacio*, L. De Salvo Souza, P. Perini and E.T. Scharlemann, *Nucl. Instr. Meth. A* **296** (1990), p. 787 W.M. Fawley, H.-D. Nuhn, R. Bonifacio, E.T. Scharlemann, in Proceedings of the 1995 Particle Accelerator Conference, p. 219

- Those extra undulators are generally referred to as "After-Burners", AB.
- The After-Burner concept is being tested at the LCLS in the form of a Second Harmonic After-Burner (SHAB).
 Z. Huang and S. Reiche, in Proceedings of the 2004 FEL Conference, 201-204





Testing the After-Burner Concept

- In the LCLS, saturation occurs well before the end of the undulator even at the shortest wavelength.
- The last 10 of the 33 LCLS undulator segments have been set aside for the SHAB test.



existing LCLS undulator





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16 keV = 0.75 Å (up to 20 keV = 0.62 Å at 15 GeV)



existing LCLS undulator

2nd harmonic after-burner

Presently, the last 5 undulator segments (U29 – U33) have been converted to SHABs







Expected Second-Harmonic Afterburner Yield







K Requirement







Gap Requirement







Gap Change Visualization







LCLS Undulator Phase Scheme



Undulator Roll-Away and K Adjustment Function



First SHAB Undulator Installed and Tested

- Gap of one undulator was increased and installed in slot U33 on 12/9/2009.
- Beam measurements done with the K-Mono



Installation and Test Schedule

- December 9, 2009
 SHAB U33 installed and tested @ 8.2 keV SHAB energy
- January May 2010 SHABs U29 – U32 modified, tuned, and installed
- May 2010 August 2010 SHABs commissioned as discussed in this talk
- Three more SHABs are ready to be installed
- Presently a maximum of 10 SHABs is considered
- Next steps are not yet decided





Diagnostics

- No absolute intensity measurement available (relying on eloss)
- Use various filters, attenuators, slits, YAG screens
- See talk by J. Welch (FROAI1) for discussion of x-ray diagnostics





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SXR Spectrometer

P3S2 YAG

Setup Steps

- Start with BBA (all undulator segments inserted)
- Set electron energy to target energy
 - 4.3 GeV (for 900 eV / 1800 eV) 2 keV 3rd harmonic mirror cutoff
 - 6.2 GeV (for 4096 eV / 8192 eV) K-Mono
 - 14.2 GeV (for 9000 eV / 18000 eV) Zr K edge
- Setting a linear taper
- Remove SHABs
- Adjust electron energy to set 2nd FEL harmonic to exact energy
- Insert 1 SHAB at a time and scan K and set to optimum
- Measure saturation point and set desired number of bunching undulators





Diagnostics for SHAB Energy = 8192 eV

- Use K Mono to remove fundamental and third harmonic.
- Use NFOV (Direct Imager) for observation.
- > PROBLEM:

K Mono very difficult to adjust



As example of use see K scan of U33, in earlier slide





Diagnostics for SHAB Energy = 18000 eV

Use Zr/Si foil to remove fundamental.

➤ Use deflection on HXR mirror pair to remove 3rd harmonic.

➤ PROBLEM:

HXR mirrors are too small for the beam.

They are difficult to align to guarantee good 3rd harmonic suppression.

MD time too short to change machine energy from <2keV operation and tune.



Zr + Si Spectrum



YAGXRAY vernier scan across Zr K edge

U01:U33; SHAB at optimum 6/29/10 taper

Bend energy 14.232 GeV

Background subtraction effectively removed nonbeam background.

Above K edge intensity from 3rd harmonic and leakage is quite low.







Observing SHAB Beam on YAGXRAY after Zr/Si



U1-33 all in (28+5 SHABs)



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18 keV SHAB Energy

Diagnostics for SHAB Energy = 1800 eV Beam



Remove third harmonic three consecutive mirrors (each with 2 keV cutoff) \geq







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P3S2 YAG

GainLength Gui







Harmonic Bunching



Adjust number of regular undulators to optimize 2nd harmonic microbunching in SHABs. Granularity is given by Segment Distance.





Debunching in SHABs due to Undulator R_{56} J. Wu

- The FEL induced energy spread in the regular undulator is heating the electron beam

 - SHABs have an R_{56} In an undulator $R_{56} = -\frac{K^2 L_u}{2\gamma_0^2} \approx -2N_u \lambda_r$
 - When the R_{56} of the SHABs spreads electrons by more than $\lambda_r/4$, the microbunching, built in the regular undulator, diffuses in the SHABs $R_{56} \frac{\Delta \gamma}{\gamma} \approx \frac{\lambda_r}{4} \Longrightarrow N_u \approx \frac{1}{8\Delta \gamma/\gamma} \approx \frac{1}{8\rho}$
 - Take $\rho = 5 \times 10^{-4} \rightarrow N_{\mu} \sim 250 \rightarrow about 2$ SHABs
 - Of course, one can **taper** the SHABs to use more segments
 - **Higher** energy FEL can have **more** SHABs, since ρ is smaller
- The ratio of energy spread to bunching amplitude can be improved with a dispersive section acting on the presaturated bunch. (similar to HGHG scheme) L.H. Yu, Phys. Rev. A 44, 5178 (1991)





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Predicted SHAB Performance



SHAB Gain Curve on Direct Imager

1800 eV SHAB Energy



- First three data points are Und 26-28 (mostly 3rd harmonic)
- Last five are SHABs (increase due to 2nd harmonic bunching)





Eloss Scans P. Emma

Kick electron beam transversely to destroy FEL and micro-bunching at selected point. Measure energy loss at dump BPM





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1800 eV SHAB Energy

More Exotic Eloss Scans



SHAB Taper improves 2nd harmonic signal by a factor of 2

1800 eV SHAB Energy



SHAB Signal on P3S2 YAG

CONSTANT TAPER





SHAB Taper improves 2nd harmonic signal by a factor of 2

1800 eV SHAB Energy



SHAB Signal on P3S2 YAG

EXTRA SHAB TAPER





Turning off the heater kills SHAB signal



Shows that SHABs act on microbunching; also demonstrates the importance of the Laser Heater





Summary

- Five SHABs generate ~0.1 mJ of 2nd harmonic power at 1.8 keV (barely detectable with E-loss method)
- Found increasing power over all five SHABs
- Reasonable agreement with simulations
- Signal is sensitive to Laser Heater setting
- Found that SHAB intensity at 18 keV (14.2 GeV) exceeds that of 3rd harmonic at same photon energy (11.6 GeV) by at least factor 2
 - Measurement was suggested by J. Frisch
 - This factor should increase to 10+ if more SHABs are installed and betafunction is reduced.
- More SHABs are ready to be installed
- May wait until somebody can use the radiation before we install them



THANK YOU FOR YOUR ATTENTION!





End of Presentation



